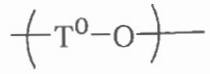
CLAIMS

1. A composition for forming a passivation film, comprising:

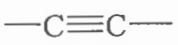
a polymer containing a unit structure of Formula (i):



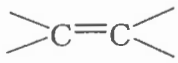
Formula (i)

(where T^0 is a sulfonyl group, a fluoroalkylene group, a cycloalkylene group, or an arylene group having a substituent, or is a combination of an arylene group optionally having a substituent and a fluoroalkylene group or a cycloalkylene group), wherein

the polymer has at least one of a group having a structure of Formula (2-A), a group having a structure of Formula (2-B), or a group having both of the structures, at an end, in a side chain, or in a main chain of the polymer:



Formula (2-A)

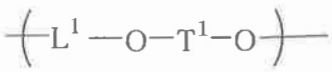


Formula (2-B)

and wherein a carbon-carbon triple bond or a carbon-carbon double bond is introduced at an end in a side chain of the polymer via an oxygen atom or a nitrogen atom.

2. A composition for forming a passivation film, comprising:

a polymer containing a unit structure of Formula (1):



Formula (1)

(where L^1 is an arylene group optionally having a substituent, or is a combination of an arylene group optionally having a substituent and a sulfonyl group, a carbonyl group, an ester group, an amido group, a sulfinyl group, or a sulfonamide group; and T^1 is a fluoroalkylene group, a cycloalkylene group, or an arylene group having a substituent, or is a combination of an arylene group optionally having a substituent and a fluoroalkylene group or a cycloalkylene group, or is a combination of an arylene group optionally having a substituent, a fluoroalkylene group, and a cycloalkylene group), wherein

the polymer has at least one of a group having a structure of Formula (2-A), a group having a structure of Formula (2-B), or a group having both of the structures, at an